

# Understanding method of User Needs at the JPO

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#### Yasunori SHIMIZU Deputy Director, Quality Management Office



## 1. Importance of Understanding User Needs

- 2. Methods of Understanding User Needs
- 3. Reflection of User Needs in initiatives

The JPO released its "Quality Policy on Patent Examination" with the aim of further improving the quality of patent examination.

This quality policy outlines the fundamental principles of quality management in patent examination.

The JPO make efforts toward enhancing quality of patent examination based on this quality policy.

Quality Policy on Patent Examination is available at *http://www.jpo.go.jp/seido\_e/s\_gaiyou\_e/pdf/patent\_policy/policy.pdf* 







#### **Fundamental Principles in Quality policy**

#### "We grant robust, broad and valuable patents."

- > "We meet wide-ranging needs and expectations."
  - $\checkmark$  High-quality patent examination has to satisfy users.
  - ✓ It is necessary to consider that patents can provide benefits and satisfaction to the society and its people.
- "We all dedicate ourselves to improving quality, cooperating with concerned persons and parties."
- >"We contribute to improving the quality of patent examination globally."
- > "We continually improve operations."
- > "We raise the knowledge and capabilities of our staff."



### Importance of Understanding User Needs

- Meeting to users'(customers') requirements is a crucial concept in general quality management
- External evaluation (especially from users) is necessary to follow PDCA cycle
- External evaluation is also one of the important index on examination quality at the JPO



## 1. Importance of Understanding User Needs

# 2. Methods of Understanding User Needs

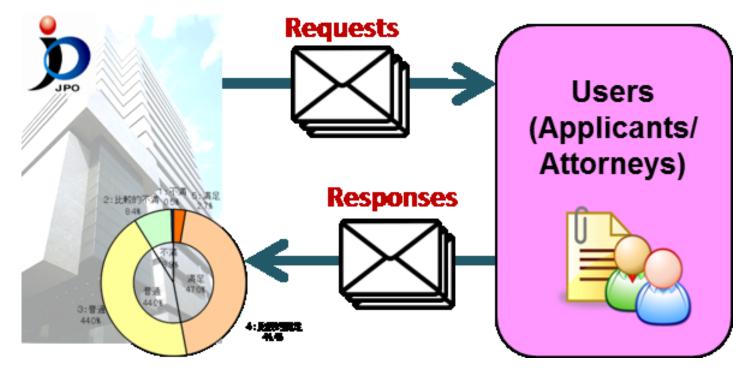
- i. User Satisfaction Survey
- ii. Acceptance of Opinions on Examination Quality
- iii. Meeting with Users on Examination Quality

3. Reflection of User Needs in initiatives

#### 2.i. User Satisfaction Survey



Since fiscal year 2012, the JPO has been conducting user satisfaction surveys every year, in order to understand the needs and expectations of users



High response rates of around 90%!!



#### Type of Questionnaires, Respondents and Number

#### **National Application Examinations**

Type of questionnaires	Respondents	Number	
	National Applicants	578 users	
(A) Overall Quality in General	Foreign Applicants	59 users	
	Attorneys	50 users	
(B) Quality on Specified Applications	2,008 applications(%)		
	(patent grant or final rejection in 2016)		

**%**random sampling

#### International Searches and International Preliminary Examinations

Type of questionnaires	Respondents	Number			
(C) Overall Quality in General	National applicants	302 users			
	Attorneys	30 users			
(D) Quality on Specified Applications	730 applications (XX) (International search report or international preliminary examination report in 2016)				

**%**random sampling



#### Questionnaire for Overall Quality in General

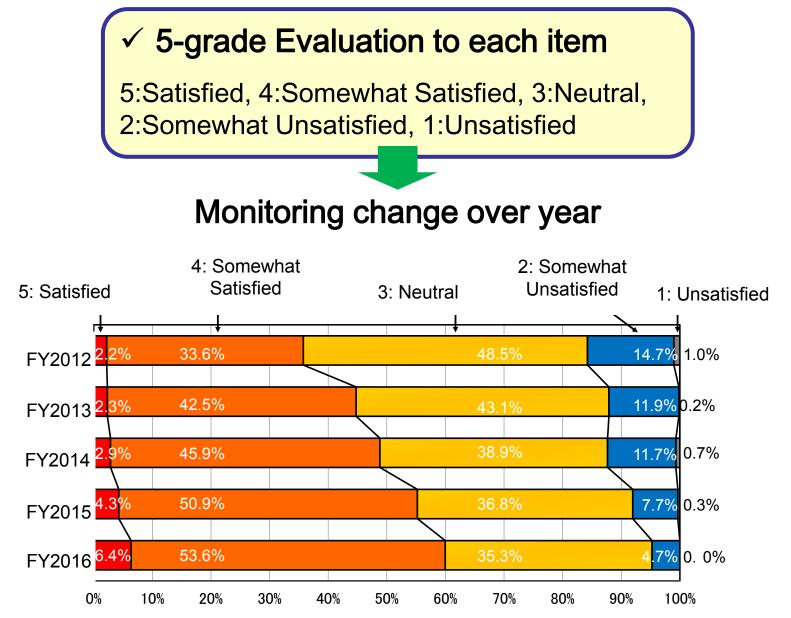
#### Evaluation Items

Overall quality on patent examination

Searches (domestic patent / foreign patent / non-patent)
Descriptions in notifications of reasons refusal/decision of refusal
Proper application of legal wordings(novelty/inventive step/clarity, etc.)
Consistency of judgements among examiners
Level of examiners' expertise in technical details
Communication (face-to-face interviews / telephone conversations)
Scope of patent right granted as a result of examination

#### 2.i. User Satisfaction Survey





Level of satisfaction on the descriptions in notifications of reasons refusal

2.i. User Satisfaction Survey



Detailed Analysis on Users' Opinion

#### Reasons why users are satisfied / unsatisfied on Specified Application

#### Example of the reasons

Searches

- Descriptions in notifications of reasons refusal/decision of refusal
- Proper application of legal wordings(novelty/inventive step/clarity, etc.)

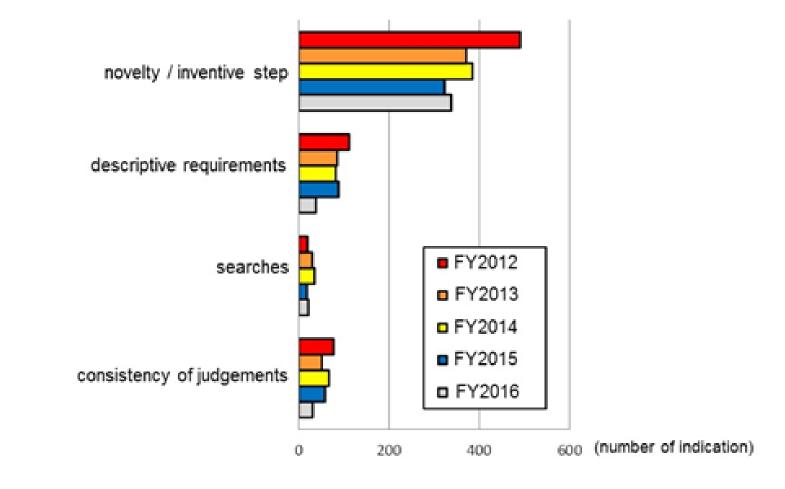
Analysis of Reasons why users are satisfied / unsatisfied







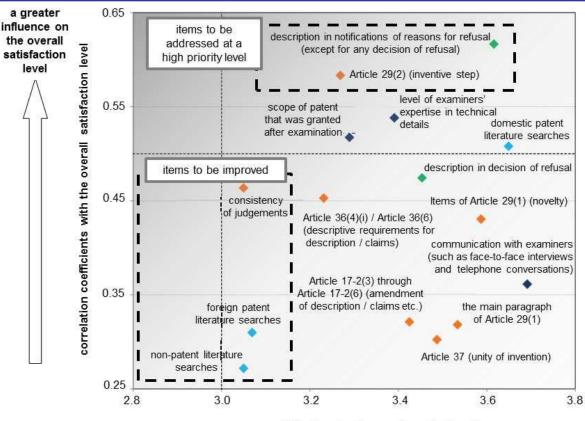
#### The number of unsatisfied opinions in User Satisfaction Survey



2.i. User Satisfaction Survey: Visualized Analysis on National Applications



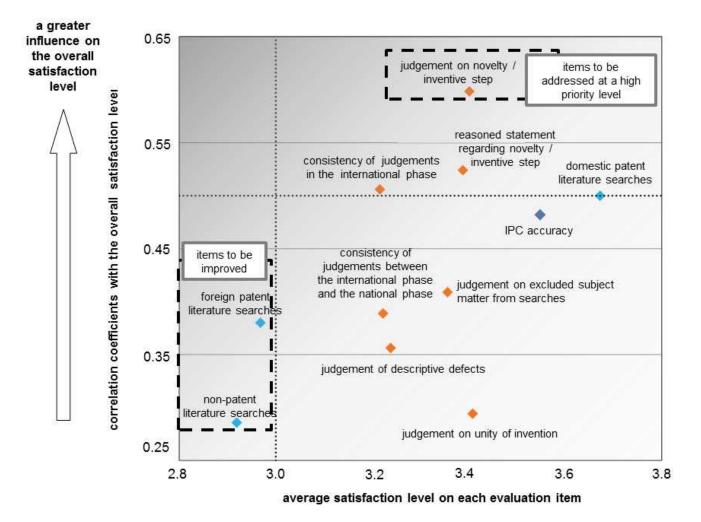
- We analyzed how much the level of user satisfaction on each item affects the overall level of satisfaction on patent examination quality, in order to visualize the priorities.
- The low satisfaction level and the high correlation coefficient of the overall level of satisfaction (Upper left side in darker background) are useful indications to recognize areas of priority.



average satisfaction level on each evaluation item



# Visualized Analysis on International Searches and International Preliminary Examinations



#### 3. User Satisfaction Survey: Report to Users

on FY2016 Annual User Satisfaction Survey on Patent Examination Quality



#### JPO website

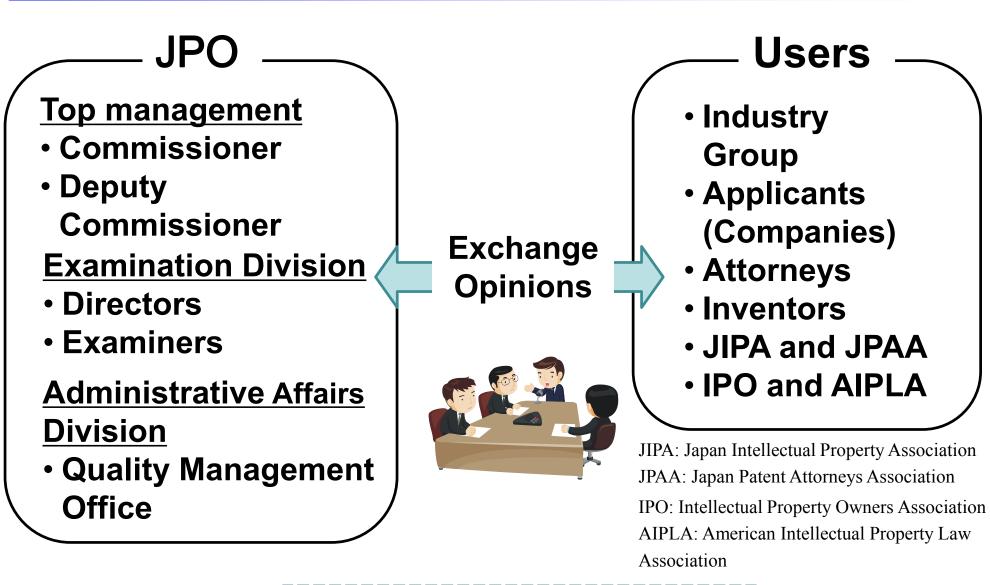
ining IP Rights	Report on FY2016 Annual User Satisfaction Survey on Patent
Patenta	Examination Quality
Utility Models	
Designs	-
Tradomarka	May 2017
Appeals/Trials	Quality Management Office Administrative Affairs Division
International Applications	
	To achieve the utmost quality of the world in terms of patent examination, it is essential that continuous efforts be made for anticiping and scheming the world of extent examination, hand as an example, the detection of the sends and
Processions for Overseas Applicants	for sustaining and enhancing the quality of patent examination, based on an accurate understanding of the needs and expectations of its users who include applicants and third parties. Therefore, the JPO has conducted a user satisfaction
	survey on gatest examination annually since FY2012 <sup>11</sup> .
Examination Quality Management	survey on gateric examination annually since F 12012
	Like in the last four surveys, this survey also had a high response rate of around \$0% from users. In this survey, the JPO
Examination Quality Management of the JPO	received a level of satisfaction around 57% for the quality of its patent examination (the total of all responses of
	"Satisfied" and "Somewhat Satisfied" on a 5-point scale). Overall, this was a rather favorable level of satisfaction with
	the quality of patent examination. Meanwhile, some practices in patent examination are still sought to be improved in
	terms of quality.
	Taking consideration of the results that were obtained from this survey, the JPO will make continuous efforts for
	sustaining and enhancing the quality of patent examination.
	The JPO is sincerely grateful to all the users who took this survey.
Click!	<ul> <li>Report on FY2016 Annual User Satisfaction Survey on Patent Examination Quality (summary)(PDF.0.45dB)</li> </ul>
	<sup>71</sup> The JPO's fiscal year runs from Agril 1 to March 31.
	Last updated 30 May 2017)
	Contact
	Quality Management Office
	Administrative Affairs Division
	Patent and Design Examination Department
	Patent and Design Examination Department Japan Patent Office

Home > Obtaining IP Rights > Examination Quality Management > Examination Quality Management of the IPO > Quality Management of Patent Examination > Report

Report on FY2016 Annual User Satisfaction Survey on Patent Examination Quality is available at

http://www.jpo.go.jp/seido\_e/quality\_mgt/user\_survey\_fy2016.htm

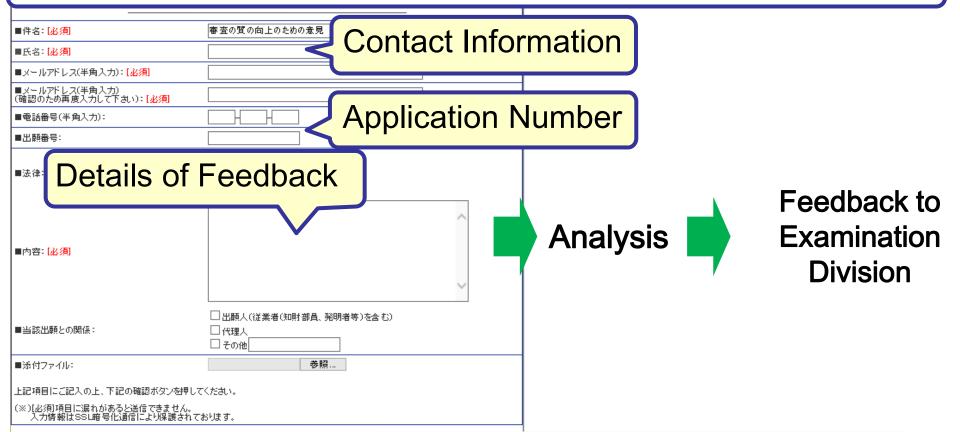




Around 360 meetings (in FY 2016)



The Quality Management Office accepts feedback from users on examination quality through the JPO website <u>anytime</u>, in addition to by telephone and FAX.



http://www.jpo.go.jp/seido/hinshitsukanri/hinshitsukanri.htm#goiken (Japanese version only)



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#### **User Needs**

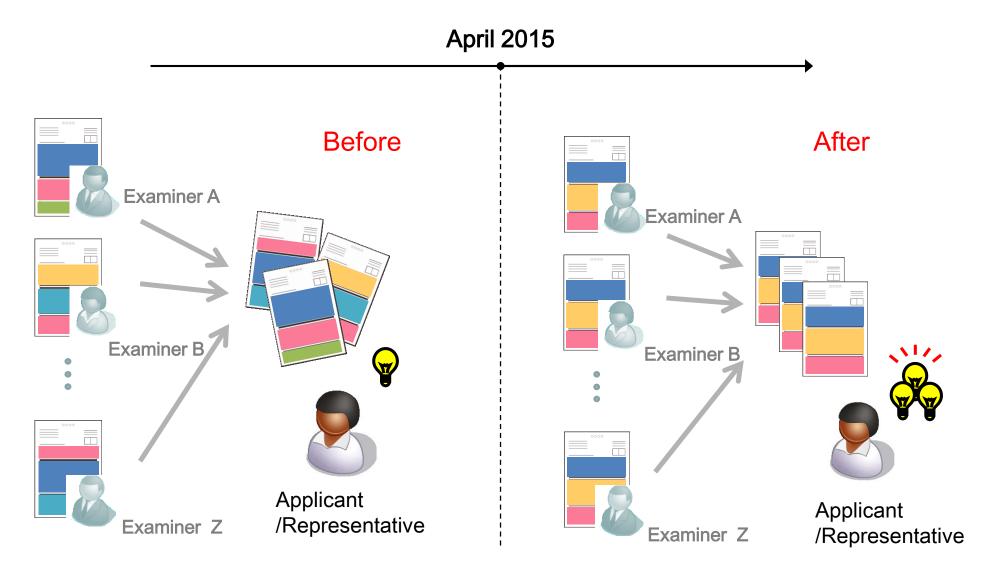
- In order to facilitate further users' understanding of examination, it is necessary to convey the content of notices of reasons for refusal in accurate and easy-to-understand manner.
- It is advisable to write in a way that users at domestic and abroad can easily understand the content in terms of the logical development of patentability judgement, and results of judgment.

#### **Corresponding Initiatives**

- Standardization of Notification Form
  - ✓ The shorthand notation of the reason for refusal should be written at the beginning of the Article.
  - The cited parts of the cited documents should be specified, if examiner refers to the cited documents in the reasons for refusal of lack of novelty, inventive step, etc.

#### 3. Reflection of user needs to initiatives





https://www.jpo.go.jp/tetuzuki\_e/t\_tokkyo\_e/efforts.htm



#### **User Needs**

It is advisable to reduce discrepancy for predictability of examination results.

#### **Corresponding Initiatives**

- Promotion of Consultation Around 50,000 cases (in FY 2016)
   Formulate guideline for managers' check (since 2015 ~)
  - \*Managers' checks are worked better as quality assurance after standardization by the guideline.

#### 为 特許庁

# Thank you for your attention!

(19) 日本国特許庁 (JP)	(12)特許	公報	(B2)	(11)特許 <b>特許</b> :	<sup>番号</sup> 第2900001 <b>号</b> (P2900001)
(45)発行日 平成21年12月1日	(2009. 12. 1)		(24)登録日	平成21年10月	1日(2009.10.1)
(51) Int. Cl.	FΙ				
G01B 12/345 (2006.		l B 12/34			
G02C 9/87 (2006.		2 C 9/87			
G01B 67/89 (2006.		IB 67/89	Z		
G01B 12/345 (2006. G01B 34/56 (2007.		B 12/345	U		
G01B 34/56 (2007.	<i>G</i> (1)	IB 34:56	請求項の数 2	(全6頁)	最終頁に続く
(21)出願番号 特願平11-	123456	(73)特許権	霍者 390000011		
(22)出願日 平成11年1	2月20日 (1999. 12. 20)		特実 花子		
(65)公開番号 特開2000-	123456 (P2000-123456A	)	東京都千代田	区霞が関4-	2 - 1
(43)公開日 平成12年6	月20日 (2000. 6. 20)	(74)代理人	123456789		
	月18日 (2000. 8. 18)		弁理士 代理	太郎	
(31) 優先権主張番号 83304359.		(72)発明者	f 発明 太郎		0 0 0 0 <b>1</b> 7 14
	1月12日 (1998.11.12)	1	神奈川県横須	質巾壱1丁目	2200番地
<ul><li>(33)優先権主張国 フランス(</li><li>(31)優先権主張番号 96/12583</li></ul>	PK)	如本学	下審査 太郎		
	月4日 (1996, 12, 4)	香工日	香宜 入印		
(33)優先権主張国 米国(US)	14H (1550, 12, 4)				
微生物の受託番号 FERM BP-32 微生物の受託番号 NRRL B-182 微生物の受託番号 NRRL B-182	92				
(54)【発明の名称】ファクシミ」 (57)【特許請求の範囲】 【請求項1】 電話回線を用いて相互通信 ラメータを通知し、通信時 含む制御信号の進し、各サブ ータ中には現れない特定の 定の識別コードを検出し、、	を行うファクシミ の端末パラメータ は該制御信号のフ フィールドの情報 識別コードを挿入	を識別する アクシミリ を分離する してファク	E	Xar	nined by PO
の端末パラメータの内容を	検出することを特定	敦とするフ			
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請求項1の装置を用いる方 【発明の詳細な説明】	法・・・・・。			_	_
請求項1の装置を用いる方 【発明の詳細な説明】 【技術分野】	法・・・・・。			_	_
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